EXHIBIT 7



Case 6:20-cv-01216-ADA Document

Patent Number:

United States Patent [19]

Date of Patent: Oct. 3, 2000 Yang et al. [45]

[11]

[54] THIN RESIST WITH NITRIDE HARD MASK FOR VIA ETCH APPLICATION

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[21] Appl. No.: 09/203,283

Dec. 1, 1998 [22] Filed:

[51] Int. Cl.⁷ H01L 21/302

[52] **U.S. Cl.** 430/5; 438/723; 438/724; 438/725; 438/692; 438/694; 438/700; 438/736

438/724, 725, 692, 694, 700, 736, 743, 744; 430/5

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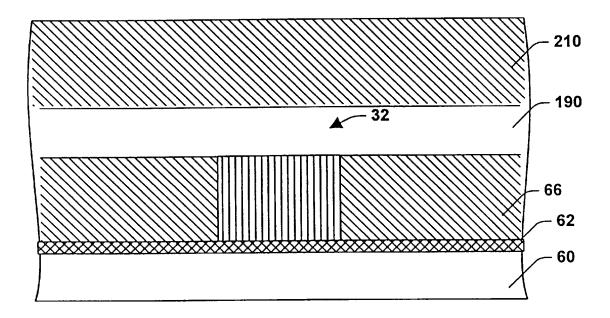
Primary Examiner—William Powell Assistant Examiner—George Goudreau

Attorney, Agent, or Firm—Amin, Eschweiler & Turocy, LLP

[57] **ABSTRACT**

A method of forming a via structure is provided. In the method, a dielectric layer is formed on an anti-reflective coating (ARC) layer covering a first metal layer; and a nitride layer is formed on the dielectric layer. An ultra-thin photoresist layer is formed on the nitride layer, and the ultra-thin photoresist layer is patterned with short wavelength radiation to define a pattern for a via. The patterned ultra-thin photoresist layer is used as a mask during a first etch step to transfer the via pattern to the nitride layer. The first etch step includes an etch chemistry that is selective to the nitride layer over the ultra-thin photoresist layer and the dielectric layer. The nitride layer is employed as a hard mask during a second etch step to form a contact hole corresponding to the via pattern by etching portions of the dielectric layer.

2 Claims, 9 Drawing Sheets



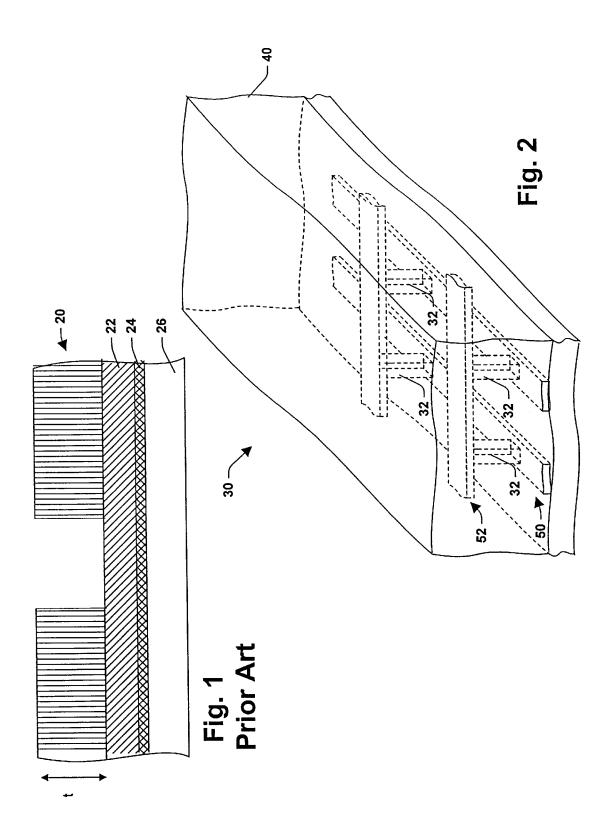


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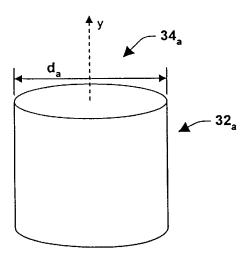


Fig. 3a

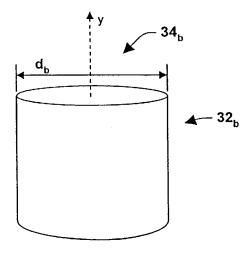
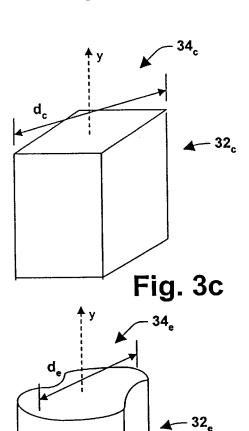


Fig. 3b





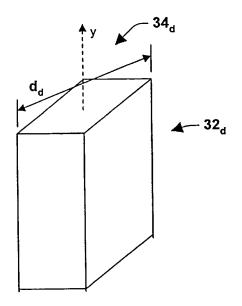


Fig. 3d

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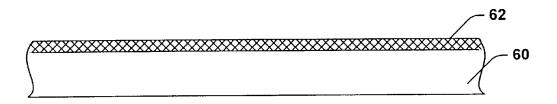


Fig. 4

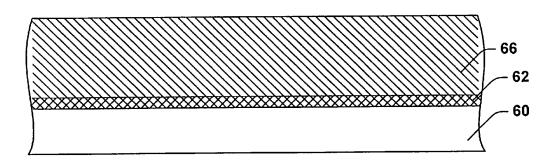


Fig. 5

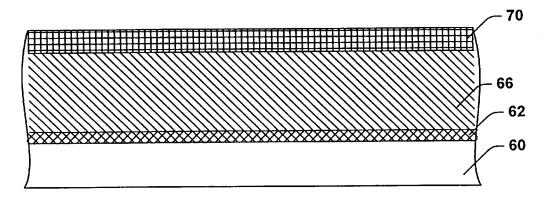


Fig. 6



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